IFW

PATENT

In re Application of:

RALF VAN BENTUM

MANFRED HORSTMANN

Serial No.: 10/624,712

Filed: July 22, 2003

For: TECHNIQUE FOR FORMING

CONTACTS FOR BURIED DOPED REGIONS IN A SEMICONDUCTOR

DEVICE

Examiner: Lan Vinh

Group Art Unit: 1765

Att'y Docket: 2000.106700/DE0122

Customer No.: 23720

RESPONSE TO OFFICE ACTION DATED AUGUST 26, 2005

Mail Stop Amendment Commissioner for Patents P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

CERTIFICATE OF MAILING 37 C.F.R 1.8

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on the date below:

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October 24, 2005

Date

Signature

This paper is submitted in response to the Office Action dated August 26, 2005, for which the three-month date for response is November 26, 2005.

No fees are believed to be due in connection with the present paper. However, should any fees be required under 37 C.F.R. §§ 1.16 to 1.21, the Director is authorized to deduct such fee from the Advanced Micro Devices, Inc. Deposit Account No. 01-0365/DE0122.¹

Reconsideration of the application in view of the following remarks is respectfully requested.

¹ In the event the monies in that account are insufficient, the Director is authorized to withdraw funds from Williams, Morgan & Amerson, P.C. Deposit Account No. 50-0786/2000.106700.